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Front Matter: Volume 9926

, "Front Matter: Volume 9926," Proc. SPIE 9926, UV and Higher Energy Photonics: From Materials to Applications, 992601 (23 November 2016); doi: 10.1117/12.2258079

SPIE.

Event: SPIE Nanoscience + Engineering, 2016, San Diego, California, United States

PROCEEDINGS OF SPIE

UV and Higher Energy Photonics: From Materials to Applications

**Gilles Lérondel
Satoshi Kawata
Yong-Hoon Cho**
Editors

**28–31 August 2016
San Diego, California, United States**

Sponsored and Published by
SPIE

Volume 9926

Proceedings of SPIE 0277-786X, V. 9926

SPIE is an international society advancing an interdisciplinary approach to the science and application of light.

UV and Higher Energy Photonics: From Materials to Applications, edited by Gilles Lérondel, Satoshi Kawata, Yong-Hoon Cho, Proc. of SPIE Vol. 9926, 992601 · © 2016 SPIE · CCC code: 0277-786X/16/\$18
doi: 10.1117/12.2258079

Proc. of SPIE Vol. 9926 992601-1

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Author(s), "Title of Paper," in *UV and Higher Energy Photonics: From Materials to Applications*, edited by Gilles Léron del, Satoshi Kawata, Yong-Hoon Cho, Proceedings of SPIE Vol. 9926 (SPIE, Bellingham, WA, 2016) Six-digit Article CID Number.

ISSN: 0277-786X

ISSN: 1996-786X (electronic)

ISBN: 9781510602434

ISBN: 9781510602441 (electronic)

Published by

SPIE

P.O. Box 10, Bellingham, Washington 98227-0010 USA

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